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Docket No.: 2328-059

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : : **EXPEDITED PROCEDURE**
Rajinder DHTNDSA, et al. : : **Response under 37 CFR 1.116**
U.S. Patent Application No. 10/032,279 : **Confirmation No. 4056**
Filed: December 31, 2001 : **Group Art Unit: 1763**
: **Examiner: ANNA M. CROWELL**

For: **PLASMA PROCESSOR IN PLASMA CONFINEMENT REGION WITHIN A
VACUUM CHAMBER**

SUPPLEMENTAL AMENDMENT UNDER RULE 116

Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

December 29, 2004

Sir:

This paper is submitted supplementary to the Amendment under Rule 116 filed on November 18, 2004 and further in reply to the Office Action mailed October 15, 2004, which was made Final. Applicants respectfully request that the following amendments as to form be entered to place this application in condition for allowance.

CERTIFICATION OF FACSIMILE TRANSMISSION
(THESE) CERTIFY THAT THIS PAPER IS BEING FACSIMI-
LE TRANSMITTED TO THE PATENT AND TRADEMARK OFFICE
ON THE DATE SHOWN BELOW

ALICE WEAVER
TYPE OR PRINT NAME OF PERSON SIGNING CERTIFICATION
Alice Weaver 12-29-04
SIGNATURE DATE
703/872-9306
FACSIMILE NUMBER